



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Patrick BROYER et al.

Group Art Unit: 3641

Application No.: 10/585,356

Docket No.: 128528

Filed: July 6, 2006

For:

PYROTECHNIC MICROSYSTEM AND METHOD FOR FABRICATING A

MICROSYSTEM

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

William P. Berridge Registration No. 30,024

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WPB:JRB/rdb

Date: November 28, 2007

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DEPOSIT ACCOUNT USE AUTHORIZATION Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461



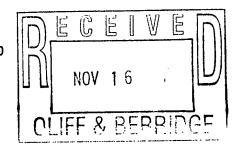
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UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450

APPLICATION	FILING or	000		Alexandria, Virginia 22313-1450 www.uspto.gov		
NUMBER 10/585,356	371(c) DATE 07/06/2006	GRP ART UNIT 3641	FIL FEE REC'D	ATTY.DOCKET.NO 128528	TOT CLAIMS	IND CLAIMS

CONFIRMATION NO. 2561

25944 OLIFF & BERRIDGE, PLC P.O. BOX 320850 ALEXANDRIA, VA 22320-4850



Date Mailed: 11/15/2007

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections

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Assignment For Published Pakent Application

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Power of Attorney: The patent practitioners associated with Customer Number 25944

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/FR05/50034 01/20/2005

Foreign Applications

FRANCE 0400720 01/27/2004

If Required, Foreign Filing License Granted: 11/13/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US 10/585,356**

Projected Publication Date: 02/21/2008

Non-Publication Request: No

Early Publication Request: No

Title

Pyrotechnic Microsystem and Method for Fabricating a Microsystem

Preliminary Class

102

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